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(12) **United States Design Patent**
Busato

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(54) **STEREOLITHOGRAPHY MACHINE**

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(30) **Foreign Application Priority Data**

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(51) **LOC (10) Cl.** **15-09**

(52) **U.S. Cl.**
USPC **D15/122**

(58) **Field of Classification Search**
USPC D18/53, 59, 50, 14, 19, 54, 36-37;
D14/301; D15/122, 135-137, 141;
D19/68

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B29C 67/0051; B29C 67/0055; B29C 67/0059
See application file for complete search history.

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(57) **CLAIM**

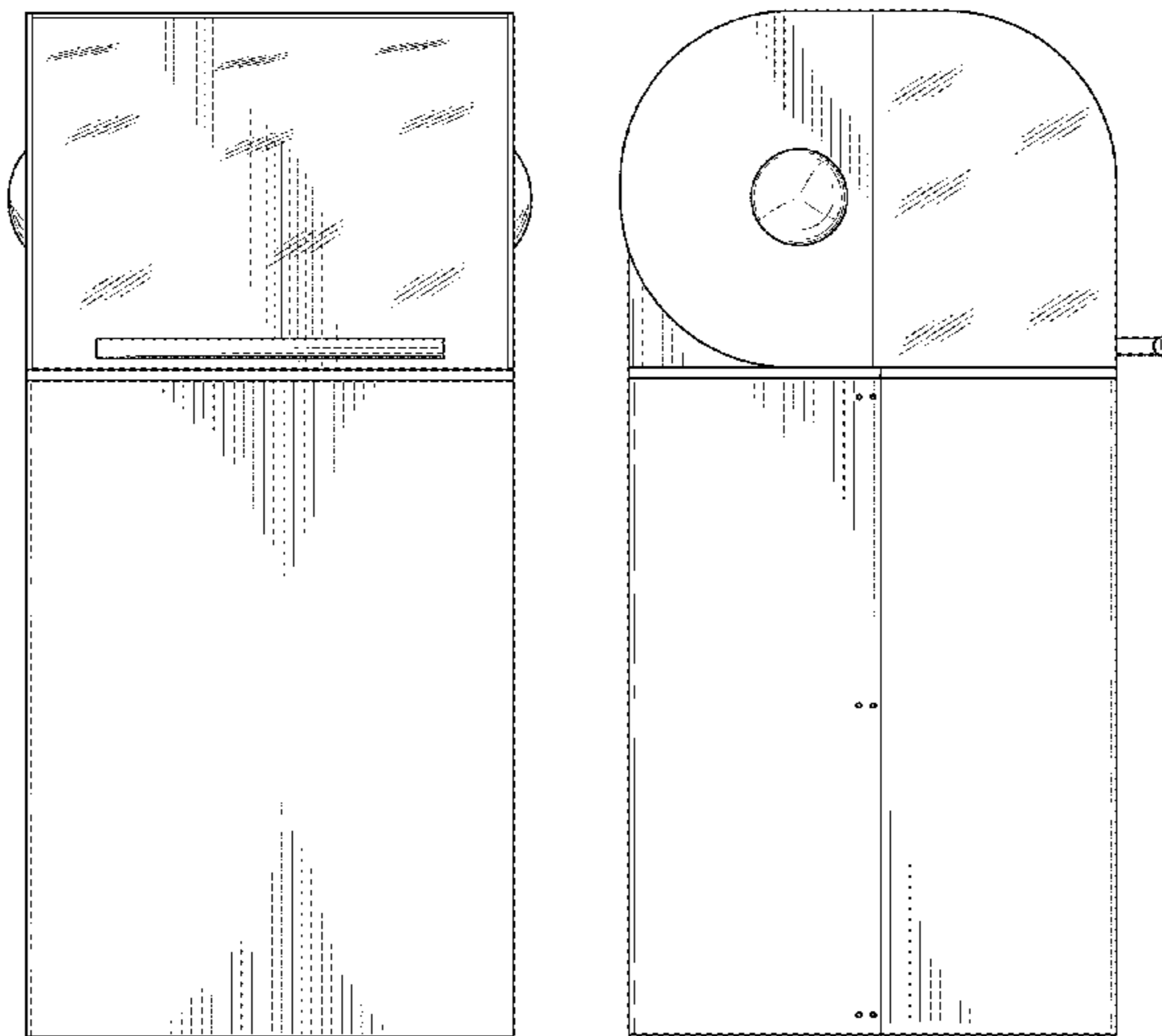
The ornamental design for a stereolithography machine, as shown and described.

DESCRIPTION

FIG. 1 is a left front perspective view of a stereolithography machine showing my new design;
FIG. 2 is a front elevational view thereof;
FIG. 3 is a rear elevational view thereof;
FIG. 4 is a left side elevational view thereof, the right side being the mirror image thereof; and,
FIG. 5 is a top plan view thereof.

The broken lines immediately adjacent to the shaded areas, encompassing unshaded regions, represent unclaimed boundaries of the claimed design, while all other broken lines are directed to environment and are for illustrative purposes only; the broken lines form no part of the claimed design.

1 Claim, 4 Drawing Sheets



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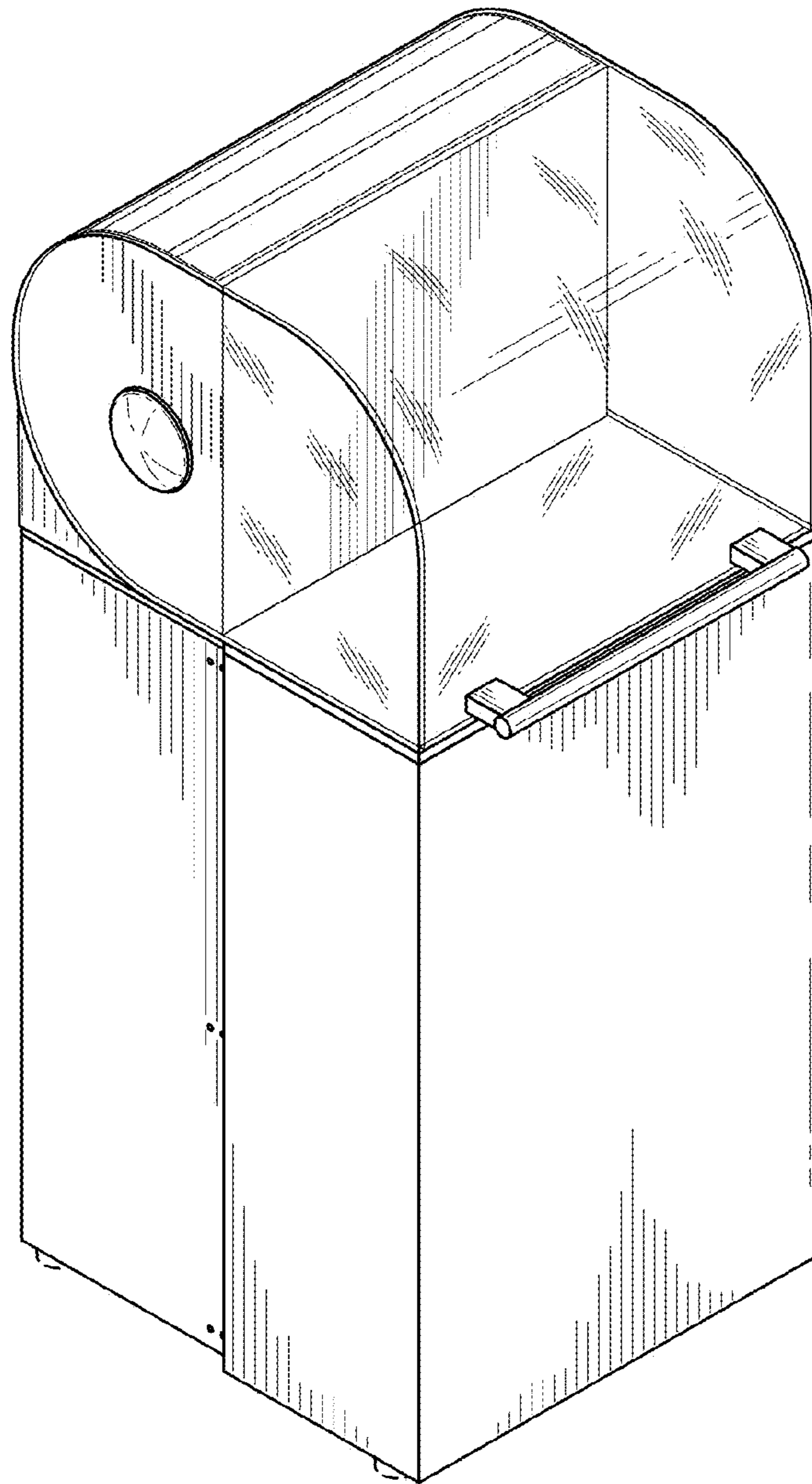


FIG. 1

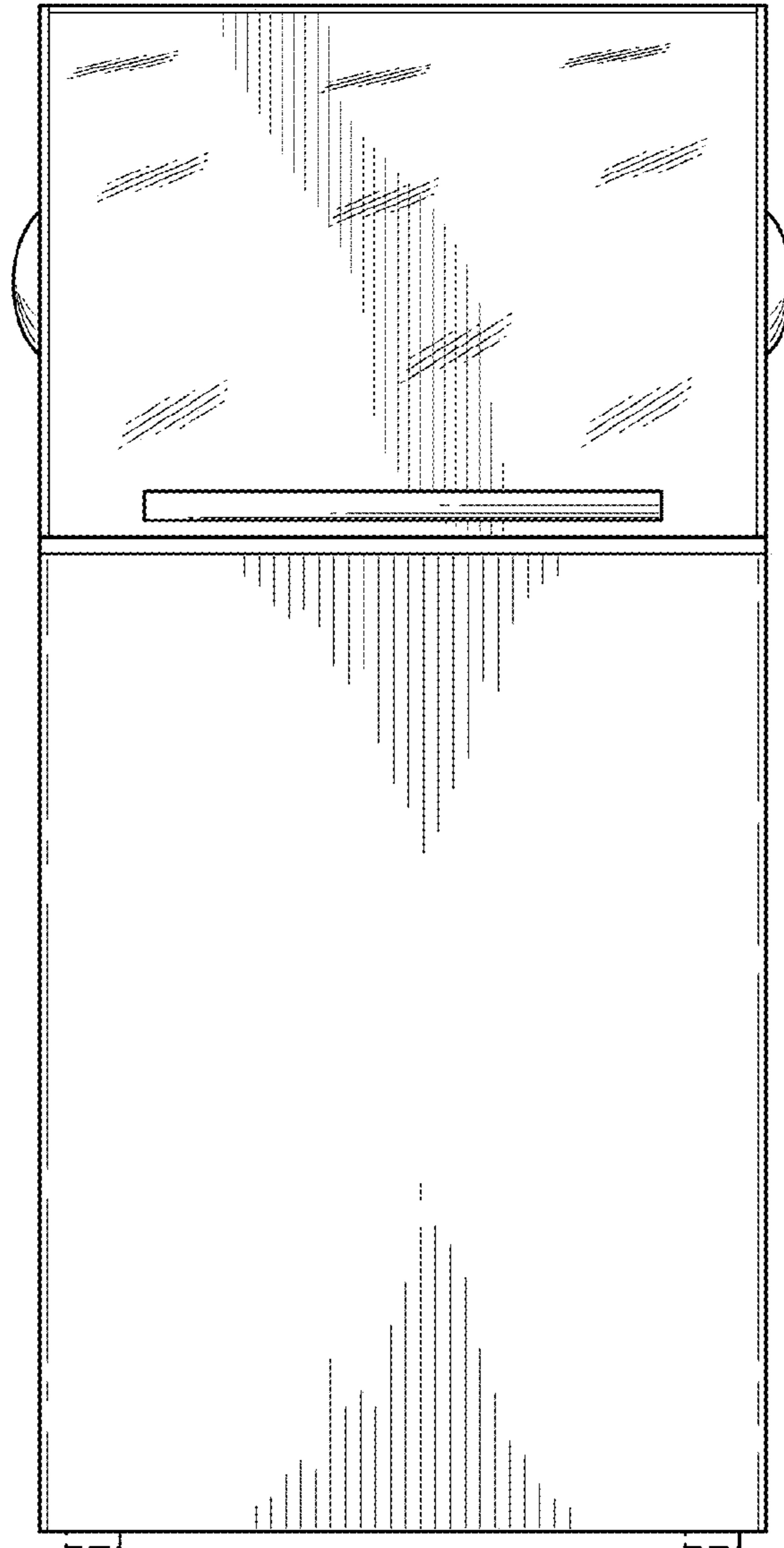


FIG. 2

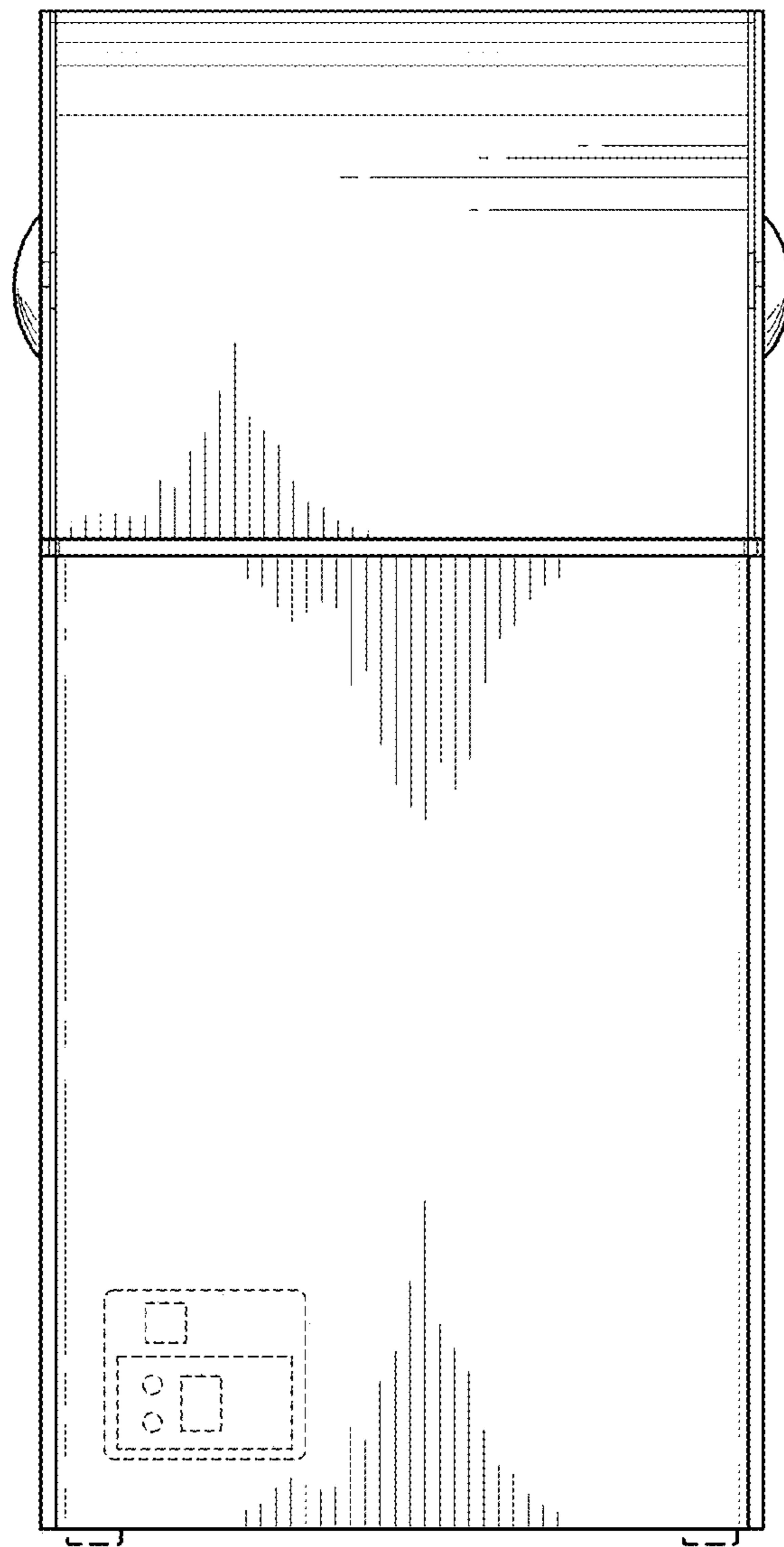


FIG. 3

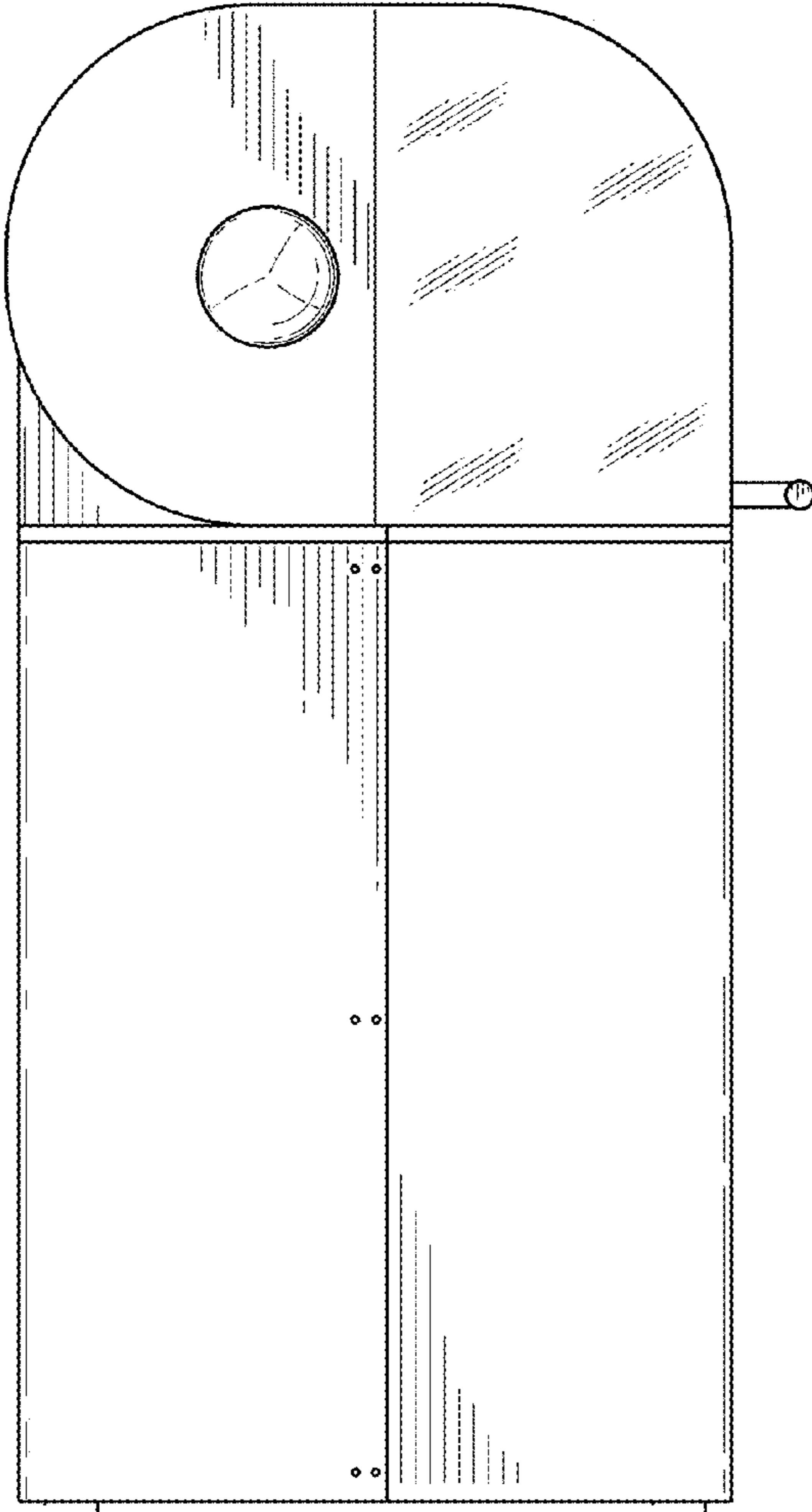


FIG. 4

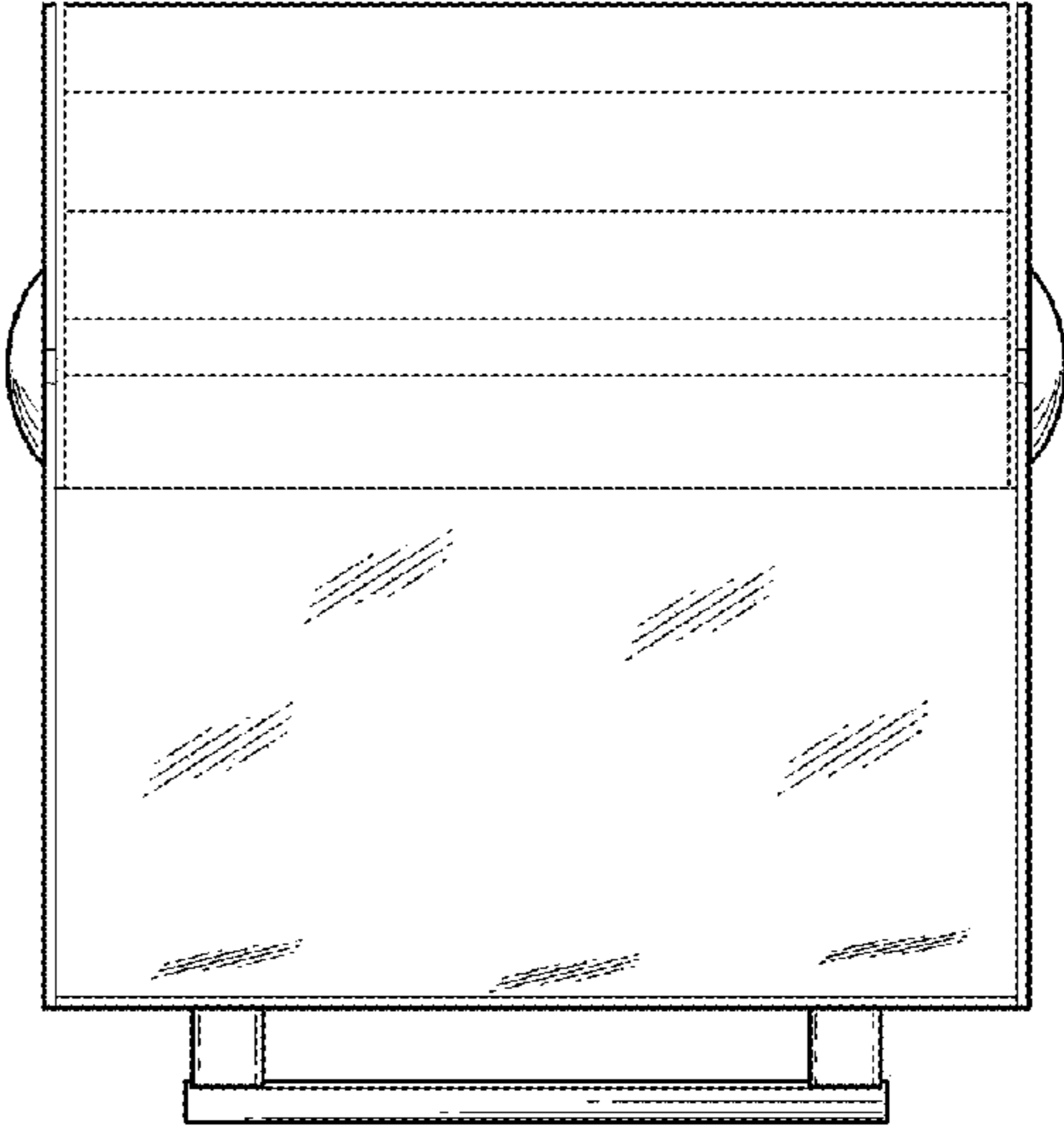


FIG. 5